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UNITED STATES PATENT APPLICATION

FOR

NMOS COMPOSITE DEVICE

VDS BOOTSTRAPPERS

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**NMOS COMPOSITE DEVICE
VDS BOOTSTRAPPERS**

CROSS-REFERENCE TO RELATED APPLICATION

This application claims the benefit of U.S. Provisional
5 Patent Application No. 60/519,041 filed November 11, 2003.

BACKGROUND OF THE INVENTION

1. Field of the Invention

The present invention relates to the field of CMOS
analog circuits and CMOS analog circuit design.

10 2. Prior Art

The design of analog circuits in state of the art CMOS
process technology involves the use of minimum channel length
devices. The benefits of minimum channel length devices are
increased device speed (i.e. ft) and reduced bulk parasitics.
15 The drawbacks of a minimum channel length device include
increased 1/f noise and channel length modulation, among
others. Ideally when a MOS device operates in saturation,
the drain current would be independent of the drain-source
voltage, thereby having an infinite output resistance. In
20 fact, however, channel length modulation causes an increase
in the drain current with drain voltage for a constant gate-
source voltage when operating in the saturation region, much

like the Early effect in bipolar junction transistors. (See
for instance Figure 2.42 on page 110 of "Bipolar and MOS
Analog Integrated Circuit Design" by Alan B. Grebene.) Thus
channel length modulation causes a decrease in the effective
5 output resistance of a device and can have derogatory effects
on the linearity of a basic source follower circuit.

BRIEF DESCRIPTION OF THE DRAWINGS

Figure 1 is a diagram illustrating a native device cascode in accordance with the present invention.

Figure 2 is a diagram illustrating the use of a native
5 device cascode in a source follower circuit.

Figure 3 is a diagram illustrating the use of a native device cascode in a source follower circuit with AC coupled biasing of the gate of the native device referenced to the output of the source follower circuit.

10 Figure 4 is a diagram illustrating the use of a native device cascode in a source follower circuit with AC coupled biasing of the gate of the native device referenced to the input to the source follower.

Figure 5 is a diagram similar to that of Figure 4, but
15 with the AC coupled bias point at the gate of device NA1 driven from an independent or replica source follower leg.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

The present invention seeks to mitigate the effects of decreased power supply rejection and increased channel length modulation in minimum or short channel length devices by using a device commonly available in advanced analog CMOS process technology called a 'Native' NMOS device, or alternatively, a low threshold NMOS device. The 'Native' device or '0 Vt' device (0V threshold voltage) is typically formed in the substrate without the use of a channel implant to alter the threshold voltage and/or to improve source-drain punch through. The benefits of the Native device are its near 0V threshold voltage that enables circuit operation under low supply voltages and with less overdrive than a standard minimum channel length device.

One embodiment of this invention (Figure 1) uses a NMOS device N1 with a Native NMOS device NA1 stacked thereon, the two devices having a common gate connection to form a three terminal composite device having a source (S) connection, a drain (D) connection and a gate (G) connection. The Native device tends to clamp the drain voltage of MOS device N1 at the threshold voltage of MOS device N1 minus the threshold of Native device NA1 (approximately 0V), or approximately the threshold voltage of MOS device N1. Thus for a given gate-source (G-S) voltage of the composite device, the drain

source voltage for MOS device N1 will tend to be isolated from variations in the drain-source (D-S) voltage for the composite device. Thus the resulting composite device has significantly lower channel length modulation and essentially the same output bandwidth as a standard NMOS device. Reduced channel length modulation results in improved linearity and power supply rejection. As such, the invention can be used in any typical source follower circuit application with significant improvements in linearity and power supply rejection. The invention specifically takes advantage of the threshold voltage difference between the stacked device and the drive device to allow a common-gate, cascode connection with superior properties of improved linearity and power supply rejection.

The present invention uses the V_t (threshold voltage) differences between 2 stacked devices, namely with a native device stacked on top of the short channel device, to form a composite device with improved output resistance. The difference in threshold voltages allows a common gate configuration to be employed while keeping the drive transistor N1 in saturation and simplifying biasing. More precisely, the following equation shows that the difference in gate-source voltage between the native transistor NA1 and basic short channel devices N1 allows the drain-source voltage on the short channel drive transistor N1 to exceed

the saturation limit. More simply, the drive transistor N1 will remain in saturation, provided the gate-source voltage on the native device NA1 does not exceed the threshold voltage of the drive transistor.

5 Equation 1 (conditions for drive transistor to be in saturation) (see pg. 109 of "Bipolar and MOS Analog Integrated Circuit Design" by Alan B. Grebene):

$$V_{ds}(N1) > V_{gs}(N1) - V_t(N1)$$

$$\text{or } V_{gs}(N1) - V_{gs}(NA1) > V_{gs}(N1) - V_t(N1)$$

10 or more simply, $V_{gs}(NA1) < V_t(N1)$

where: V_{ds} = drain source voltage when
 conducting current I (or I plus the load
 current, i.e. typically the operating
 current for the device)

15 V_{gs} = gate source voltage when conducting
 current I (or I plus the load current,
 i.e. the operating current for the
 device)
 V_t = threshold voltage

20 Figure 1 depicts the invention as a composite device comprised of NMOS device N1 with a stacked native NMOS device NA1. The performance can be compared to a single NMOS device in three key areas: output resistance, linearity and available input range. Compared to a single NMOS device, the

output resistance R_o for the composite transistor is increased by Equation 2.

Equation 2: R_o is increased by a factor:

$$1 + R_o(NA1)/R_o(N1) + (g_m(NA1) + g_{mb}(NA1)) * R_o(NA1)$$

5 or R_o is increased approximately by the factor:

$$(g_m(NA1) + g_{mb}(NA1)) * R_o(NA1)$$

where: g_m = change in drain current with a
change in the gate-source voltage
 g_{mb} = change in drain current with a
10 change in the body-source voltage

For typical device parameters, equation 2 predicts a 5
to 10 times increase in effective output resistance of the
composite transistor with the use of the stacked native
device, resulting in improvements in power supply rejection
15 and in linearity when used as a source follower.

The small signal gain of a source-follower circuit is
given in Equation 3a.

$$\text{Equation 3a: } V_o/V_i = 1/(1 + g_o/g_m)$$

$$\text{where } g_o/g_m = (dX_d/dV_{ds}) * (V_{gs} - V_t) / (2 * L_{eff})$$

20 where the new parameters are defined as:

g_o = the change in drain current with a change in
the drain-source voltage
 L_{eff} : effective channel length

X_d : drain-channel depletion region width

Also $g_{mb} = 0$ assuming an isolated device well
connected to the source

Although the term g_o/g_m is fairly linear with a very
5 small signal, for large signals as commonly processed by an
A/D converter, the term is significantly non-linear as the
transistor is biased in saturation and in the triode-
saturation transition region of operation. Improving the
distortion requires maximizing g_m and minimizing g_o .

10 Unfortunately for a single transistor, this is contradictory,
as g_m and g_o are proportional to L_{eff} (i.e. effective channel
length) and bias current.

Figure 2 shows the use of a stacked native device in a
source follower circuit. Here the composite device is
15 coupled between the power supply $AVDD$ and ground GND , with
current source I providing a pull-down current for the output
 V_{out} . In some applications, the pull-down may be provided by
the load itself as connected to the output V_{out} . By using a
stacked native device in a source follower circuit as shown
20 in Figure 2, the small signal gain can be expressed
approximately as Equation 3b.

Equation 3b: $V_{out}/V_{in} = 1/(1 + g_{oeff}/g_{meff})$

where $g_{oeff} = [g_o(NA1) * g_o(N1)]/[g_m(NA1) +$
 $g_{mb}(NA1)]$

or more simply, since $g_{mb}(N1)$ is small by design:

$g_{oeff} = g_o(N1) * [g_o(N1)/g_m(N1)]$, and

$g_{meff} = g_m(N1) + g_o(N1) * [g_o(N1)/g_m(N1)]$

where: eff designates the value of the

5 respective parameter for the composite transistor

Again, for typical device parameters, g_{oeff} is reduced by a factor of 5 to 10, while the effective g_m of the composite device benefits from a reduced output conductance as well. The combined improvements in these two terms

10 significantly improve the large signal linearity of the basic source-follower circuit.

Obtaining optimum linearity requires precise control of the voltage across the drain-source (V_{ds}) of drive device N1 over temperature and process corners. A possible circuit

15 variant to achieve this control is shown in Figure 3. Here the gate of the stacked native device is driven by the source follower output through an AC coupling capacitor. Equation 4 shows that the drain-source voltage on device N1 is determined by the difference between bias voltages V_{bias1} and
20 V_{bias2} . This difference can be made a function of $V_{gs}(N1)$ and can thus be made to yield a constant bias over process and temperature.

Equation 4: $V_{ds}(N1) = V_{bias1} - V_{bias2} - V_{gs}(N1)$

Where: V_{bias1} = the gate bias voltage on the

Native device NA1

Vbias2 = the output bias voltage on the
Short channel device NA1

Figure 3 depicts self-biasing the gate of the native
5 device through an AC coupling capacitor C1. The DC bias
level at the gate of the native device NA1 is set through a
large bias resistor R1 connected to a common-mode reference
voltage. There are several advantages to the configuration
shown in Figure 3. First, the DC bias level may be generated
10 from a common reference circuit that also provides a
reference voltage for either the source follower input or
output common-mode voltage in a differential output circuit.
By having the common mode voltages at the native NMOS gate
and the source follower output (Figure 3) or input (Figure 4)
15 referenced to the same source, excellent tracking of the Vds
(i.e. drain-source bias voltage) of the minimum channel
length NMOS may be obtained over temperature and process
corners. Maintaining an optimum Vds biasing of the minimum
channel length NMOS is important to maintaining excellent
20 linearity over temperature and process corners.

The use of the present invention allows the achievement
of excellent linearity for a source follower circuit in a low
voltage supply, state of the art CMOS process technology.
Excellent linearity is an essential property for such

applications as a high resolution, high quality analog to digital converter. Achieving the maximum bandwidth and sampling rate requires the usage of minimum channel length devices because of their improved speed (i.e. ft) and reduced bulk parasitics. However, as the channel length is reduced, the output conductance increases significantly and causes degradation in the circuit linearity. This invention allows a significant improvement in the linearity of the basic source follower, while maintaining adequate headroom for large signal processing.

Thus, as CMOS technologies scale to lower channel lengths, one of the main sources of non-linearity is channel-length modulation. Also, as CMOS technology scales the supply voltage is reduced, prohibiting the use of a conventional cascode device. The native device cascode of the present invention solves both problems as it 1) increases the impedance relative to the power supply and thus reduces the effect of channel-length modulation, and 2) has a small V_{gs} which allows it to be compatible with scaling/reduced supply voltages.

Although the present invention has been disclosed in reference to a NMOS native or '0 V_t ' device stacked on a minimum channel length NMOS device, the circuit can be implemented with any device with a smaller V_t than the

minimum channel length device. For example, medium V_t (higher than zero but less than the threshold of device N1) devices exist in most advanced CMOS process technologies and may possibly be employed in implementing a circuit of the type described here. The present invention utilizes the threshold voltage differences between two stacked devices, namely with the native or lower threshold device stacked on top of the basic short channel device, to form a composite device with improved output resistance. The difference in threshold voltages allows a common gate configuration to be employed while keeping the drive transistor in saturation and simplifying biasing.

Figure 3 shows an embellishment of the circuit implemented with an AC coupled bias of the native device (NA1) gate. The AC coupled bias can also be derived directly from the 'VIN' terminal. In other words, the AC-coupled capacitor can be connected between nodes 'VIN' and the gate of the native device (Figure 4). The AC coupled bias point at the gate of device NA1 can also be driven from an independent or replica source follower leg, as shown on Figure 5. Here replica transistors N' and NA' and current source I' provide a replica of the output of the primary composite device for coupling to the bias control. This may have the additional benefit of reducing the capacitive loading of the drive transistor N1 of the primary composite

device. It does somewhat increase the capacitive loading on the input signal V_{in} , though the replica devices may be scaled downward in size to minimize this effect.

In the foregoing disclosure, certain embodiments of the invention have been described in detail, not for purposes of limitation, but rather for purposes of conveying a more general understanding of various aspects of the invention. Thus while certain preferred embodiments of the present invention has been disclosed and described herein, it will be understood by those skilled in the art that various changes in form and detail may be made therein without departing from the spirit and scope of the invention.